U.S. Department of Commerce, Patent and Trademark Office						y Docket N	o.	Serial No.		
					M-	5319 US	_	Unussigned	•	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT						olicant(s)	10/75	898		
(Use several sheets if necessary)						Yin S. Tang				
						ng Date	Group 28	Group 2273		
								Unessigned	Unaccigned	
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				ot citation is in confo						

DAVID SPECTOR PRIMARY EXAMINER